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September 27, 2005

MAIL STOP PCT

Commissioner for Patents
P.O. BOX 1450
Alexandria, VA 22313-1450

PCT/JP2004/003992
-filed March 23, 2004

Re: Application of Akira KOBAYASHI, Tsunehisa NAMIKI, Hiroko HOSONO,
Hideo KURASHIMA, Hajime INAGAKI, and Toshihide IEKI
CHEMICAL VAPOR DEPOSITED FILM BASED ON A PLASMA CVD
METHOD AND METHOD OF FORMING THE FILM
Assignee: TOYO SEIKAN KAISHA, LTD.
Our Ref: Q90606

Dear Sir:

The following documents and fees are submitted herewith in connection with the above application for the purpose of entering the National stage under 35 U.S.C. §371 and in accordance with the Patent Cooperation Treaty:

- ☑ a copy of the executed Declaration and Power of Attorney.
- ☑ an English translation of the International Application.
- ☑ eight (8) sheets of drawings (Figs. 1-8).
- ☑ a copy of Notification Concerning Submission or Transmittal of Priority Document.
- ☑ a copy of the executed Assignment and PTO 1595 form.
- ☑ an Information Disclosure Statement and a copy of the ISR.
- ☑ a PTO/SB/08 A & B (modified) listing the ISR references.
- ☑ **it is expressly requested that the national stage of processing be commenced immediately in accordance with 35 U.S.C. § 371(f).**

In addition to the documents submitted herewith, it is assumed that copies of the International Application, the International Search Report and cited references, the International Preliminary Examination Report, and any Articles 19 and 34 amendments as required by §371(c) will be supplied directly by the International Bureau, but if further copies are needed, the undersigned will undertake to provide them upon request.

The Government filing fee is calculated as follows:

Total claims	<u>14</u>	-	20	=	_____	x \$50.00 =	<u>\$0.00</u>
Independent claims	<u>2</u>	-	3	=	_____	x \$200.00 =	<u>\$0.00</u>
Base Fee							<u>\$300.00</u>
Search Fee*							<u>\$400.00</u>
Examination Fee*							<u>\$200.00</u>



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TOTAL FILING FEE

\$900.00

Recordation of Assignment

\$ 40.00

TOTAL FEE

\$940.00

* The international search fee for all claims was not paid to the USPTO, as the ISA, but the ISR is being submitted herewith.

Checks for the statutory filing fee of \$900.00 and Assignment recordation fee of \$40.00 are attached. The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this transmittal letter is attached.

Priority is claimed from:

<u>Country</u>	<u>Application No</u>	<u>Filing Date</u>
Japan	2003-92265	March 28, 2003
Japan	2003-206714	August 8, 2003

Respectfully submitted,

Abraham J. Rosner
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WASHINGTON OFFICE

23373

CUSTOMER NUMBER

Date: September 27, 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of
KOBAYASHI, Akira et al.
Application No. PCT/JP2004/003992
International Filing Date: March 23, 2004
For: Chemical Vapor Deposited Film based on a Plasma CVD Method and
Method of Forming

VERIFICATION OF TRANSLATION

Honorable Commissioner of Patents and Trademarks
Washington, D.C. 20231

KEIJI TOKIEDA residing at 2-20-204, Kaitori 2-chome, Tama-shi,
Tokyo, Japan, declares:

(1) That I know well both the Japanese and English
languages;

(2) that I translated the annex to the International Preliminary
Examination Report of the International Application No.
PCT/JP2004/003992 from Japanese to English;

(3) that the attached English translation is a true and correct
translation of the annex to the International Preliminary Examination
Report of the International Application No. PCT/JP2004/003992 to
the best of my knowledge and belief; and

(4) that all statements made of my own knowledge are true
and that all statements made on information and belief are believed
to be true, and further that these statements are made with the
knowledge that willful false statements and the like are punishable
by fine or imprisonment, or both, under 18 USC 1001, and that such
false statements may jeopardize the validity of the application or
any patent issuing thereon.

Date: September 15, 2005


Keiji Tokieda